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# Introduction

A magnetic tunnel junction (MTJ) is an important spintronic device, which consists of two ferromagnets divided by a thin insulating barrier.<sup>1,2</sup> MTJs are widely utilized in magnetic random-access memory, hard disks, and magnetic sensors, etc.<sup>3</sup>–<sup>6</sup> Furthermore, much efforts have been put into the relevant research for MTJs since the tunneling magnetoresistance (TMR) effect was firstly discovered in Fe/Ge/Co multilayer films.<sup>7-9</sup> Herein, the TMR ratio is regarded as one of the most important factors for estimating the performance of MTJs. To enhance the TMR ratio, an effective method involves employing intrinsic magnetic materials with high spin polarizabilities as the electrode material.<sup>10,11</sup> In early years, three-dimensional (3D) magnetic metals such as Fe, Ni, and Co are employed as the ferromagnetic electrodes in MTJs.<sup>12</sup> Unfortunately, the limited spin polarizations lower than 50% result in low TMR ratios for



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Two-dimensional (2D) transition metal carbides (MXenes) with intrinsic magnetism and half-metallic features show great promising applications for spintronic and magnetic devices, for instance, achieving perfect spin-filtering in van der Waals (vdW) magnetic tunnel junctions (MTJs). Herein, combining density functional theory calculations and nonequilibrium Green's function simulations, we systematically investigated the spin-dependent transport properties of 2D double transition metal MXene ScCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub>based vdW MTJs, where  $SCz_2C_2F_2$  acts as the spin-filter tunnel barriers,  $1T-MoS_2$  acts as the electrode and 2H-MoS<sub>2</sub> as the tunnel barrier. We found that the spin-up electrons in the parallel configuration state play a decisive role in the transmission behavior. We found that all the constructed MTJs could hold large tunnel magnetoresistance (TMR) ratios over 9  $\times$  10<sup>5</sup>%. Especially, the maximum giant TMR ratio of 6.95  $\times$  10<sup>6</sup>% can be found in the vdW MTJ with trilayer 2H-MoS<sub>2</sub> as the tunnel barrier. These results indicate the potential for spintronic applications of vdW MTJs based on 2D double transition metal MXene ScCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub>. PAPER<br> **(A)** Cheek for undates<br> **(A)** Cheek for undates<br> **Could Example 10 and the control of the con** 

these 3D magnetic metals.<sup>13</sup>–<sup>15</sup> It is interesting to note that the TMR ratios of MTJs could be improved to a higher level by employing half-metallic (HM) materials as electrodes.<sup>16-18</sup> This is because HM materials possess 100% spin polarization theoretically.<sup>19</sup> However, controlling the quality of the interface between the electrode materials and barrier layers is one of the thorny challenges in 3D HM material-based MTJs.<sup>20</sup> When constructing the MTJs by cleaving 3D materials, the surface dangling bonds will inevitably cause atomic distortion, disorder, and point defects, which could strengthen the interfacial scattering, and lead to the reduction of the TMR ratio.<sup>21</sup>

Recently, the successful synthesis of intrinsic magnetic twodimensional (2D) materials, such as  $\text{Cr}_3$ ,<sup>22</sup>  $\text{Cr}_2\text{Ge}_2\text{Te}_6$ ,<sup>23</sup> and  $Fe<sub>3</sub>GeTe<sub>2</sub><sup>24</sup>$  has opened a new horizon for spintronic devices. Constructing van der Waals (vdW) MTJs via perpendicularly stacking magnetic and dielectric 2D materials together through vdW interactions offers impressive performance with high TMR ratios.<sup>25</sup> For example, a TMR ratio of 160% has been experimentally obtained in  $Fe<sub>3</sub>GeTe<sub>2</sub>|h-BN|Fe<sub>3</sub>GeTe<sub>2</sub> vdW MT]$ s at low temperatures.<sup>26</sup> Moreover, the TMR ratio of graphene/CrI<sub>3</sub>/graphene vdW MTJ up to 19 000% has been experimentally realized by increasing the CrI<sub>3</sub> layer thickness.<sup>27</sup> It is theoretically predicted that a giant zero-bias TMR ratio of up to 48 000% can be achieved using CrOCl/CrOX bilayer as the spin-filter tunnel barriers.<sup>28</sup> On the other hand, the vdW MTJs based on  $1T\text{-}VSe<sub>2</sub>$ possess a high TMR ratio of 5600%, and the TMR ratio is sharply increased to  $1.7 \times 10^5$ % by inserting 2H-MoSe<sub>2</sub>.<sup>29</sup> Two kinds of 6,6,12-graphyne-based molecular magnetic tunnel

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junctions have novel transport behaviors, and the maximum order of magnitude of tunneling magnetoresistance values reaches 10<sup>6</sup>%.<sup>30</sup> Wang et al. reported the spin-dependent transport properties of a molecular junction made of two manganese phthalocyanine molecules linked by single-walled carbon nanotubes and predicted a high spin-filter efficiency and magnetoresistance ratio.<sup>31</sup> However, it is still challenging to develop 2D materials with intrinsic magnetism to achieve giant TMR ratios in MTJs.

Among various 2D materials, 2D transition metal carbides/ nitrides (MXene) materials have attracted much attention due to their fascinating tunable physical and chemical properties from the remarkable variety of chemical diversity.<sup>32</sup>–<sup>34</sup> MXenes have a general formula of  $M_{n+1}X_nT_x$ , where M, X, and T represent early transition metals, carbon/nitrogen, and the functional groups (such as O, OH, and F), respectively.<sup>35</sup> It is worth noting that MXene  $Cr_2C$  without the surface functional groups is predicted to have intrinsic half-metallicity, and ferromagnetic to antiferromagnetic transitions accompanied by metal-toinsulator transitions can be observed after adsorbing different surface functional groups.<sup>36</sup> Moreover, some intrinsic magnetic MXenes, such as  $Cr_2NX_2$   $(X = O, F, OH),$ <sup>37</sup>  $Mn_2CT_2$   $(T = F, Cl,$ OH, O, and H)<sup>38</sup> are found to possess HM polarization nature and are proposed as potential candidates for vdW MTJs or spin filters. $39,40$  Apart from that, double transition metal (DTM) MXenes, including two different transition metals with the general formula of  $M_nM_2^{'}X_{n+1}T_{x}^{41,42}$  offer more possibilities for fantastic magnetic properties.<sup>43</sup>–<sup>45</sup> Recently, impressive intrinsic magnetic properties have been found in HM DTM MXenes, such as  $SCr_2C_2F_2$ ,  $ZrCr_2C_2H_2$  and  $YCr_2C_2H_2$ .<sup>46</sup> Herein,  $SCr_2$ - $C_2F_2$  presents a high Curie temperature of 230 K based on the Metropolis Monte Carlo (MC) simulations. Although  $T_{\rm C}$  could be theoretically overestimated, recently good agreement between theoretical results and experimental values have been achieved, for instance, in the case of CrI<sub>3</sub> and Fe<sub>3</sub>GeTe<sub>2</sub>.<sup>46,47</sup> The MC predicted  $T_{\rm C}$  of 230 K indicates that ScCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub> is anticipated to achieve distinguished MTJ performance as the ferromagnetic electrodes. Therefore, a systematical understanding and optimization of  $SCr_2C_2F_2$ -based vdW MTJs are of great interest and importance. Paper<br>
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In this work, by employing  $SCCr_2C_2F_2$  as the spin-filter tunnel barriers,  $1T-MoS<sub>2</sub>$  and  $2H-MoS<sub>2</sub>$  respectively, as the electrode and tunnel barrier, we have designed and optimized the 1T- $MOS_2/SCCr_2C_2F_2/2H-MOS_2/SCCr_2C_2F_2/1T-MOS_2$  vdW MTJs with different stacking configurations and tunnel barrier layer numbers. The interlayer charge transfers, spin-dependent transmission coefficients, spectra projected local density of states, and TMR ratios in the equilibrium state of the constructed vdW MTJs were investigated. The negative binding and formation energies of  $SCr_2C_2F_2/1T-MoS_2$  and  $SCr_2C_2F_2/2H MoS<sub>2</sub>$  heterostructures demonstrate that different layers could stack spontaneously in experiments. Besides, the energetically favorable stacking-II of the  $SCCr_2C_2F_2/1T-MoS_2$  interface and stacking-I configurations for the  $SCr_2C_2F_2/1T-MoS_2$  interface are selected to construct the vdW MTJs, which will increase the experimental feasibility. Furthermore, it reveals that the monolayer  $SCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub>$  can maintain half-metallicity with perfect polarization after application in the vdW MTJs. Large TMR ratios of over  $9 \times 10^5$ % are found in all the constructed vdW MTJs, and the maximum TMR ratio of 6.95  $\times$  10<sup>6</sup>% was detected in such vdW MTJ with a trilayer  $2H-MoS<sub>2</sub>$  tunnel barrier. Our findings demonstrate that such DTM MXene-based vdW MTJs have application potential in spintronics.

# Computational methods

In order to obtain the interlayer structures before modeling the vdW MTJs, the different stacking configurations for  $SCCr_2C_2F_2/$ 1T-MoS<sub>2</sub> and ScCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub>/2H-MoS<sub>2</sub> heterostructures were built using the ALKEMIE platform,<sup>48,49</sup> and investigated based on the density functional theory (DFT) calculations using the Vienna Ab initio Simulation Package (VASP).<sup>50</sup> The generalized gradient approximation (GGA) with Perdew-Burke-Ernzerhof (PBE)<sup>51</sup> was used for the exchange and correlation potentials. To better describe the correlation effect of localized 3d electrons in Cr atoms, the GGA + U method with the on-site effective interaction parameter  $U = 3.0$  eV was used.<sup>52</sup> The plane-wave cut-off energy of 500 eV and 12  $\times$  12  $\times$  1 K-points were utilized for the optimization and self-consistent calculations. The DFT-D3 method<sup>53,54</sup> was adopted to describe the interlayer van der Waals force. To avoid the interlayer interaction, a 20 Å vacuum was added on top of the 2D materials. The heterostructures were relaxed with the convergence energy for electrons and convergence forces for atoms to 1  $\times$  10<sup>-5</sup> eV and 0.01 eV  $\AA^{-1}$ , respectively.

The optimizations and spin-dependent transport calculations of vdW MTJs were implemented using the QuantumWise Atomistix Toolkit (QuantumATK) Q-2021.06 package,<sup>55</sup> based on DFT combined with the nonequilibrium Green's function (NEGF).<sup>56</sup> The generalized gradient approximation (GGA) of the Perdew-Burke-Ernzerhof (PBE)<sup>51</sup> functional with a linear combination of atomic orbitals (LCAO) norm-conserving PseudoDojo pseudopotential<sup>57</sup> were included to deal with the electron exchange and correctional interactions. The double-zeta basis set used to expand wave functions was employed for the calculations.<sup>58</sup> The plane-wave cut-off of 105 Hartree was employed,  $10 \times 10 \times 1$  Monkhorst *k*-point meshes were used for the optimization of the MTJs before performing the spindependent transport calculations, and the convergence criterion of the force was set to 0.01 eV  $\AA^{-1}$ . The electron temperature was set at 300 K, which was determined by the Fermi–Dirac distribution *via* the occupation number of each state. When performing the self-consistent calculation,  $10 \times 10 \times 1$  Monkhorst k-point meshes were utilized for the central scattering regions. Besides, inspired by the set of electrodes of the recently proposed NiI<sub>2</sub>/In<sub>2</sub>Se<sub>3</sub> multiferroic devices,<sup>59</sup> the dense enough kpoints set was required for the electrodes along the transport direction since they are regarded as the periodic bulk structures for the transport calculations. The Monkhorst  $k$ -point meshes for the electrodes were set to  $10 \times 10 \times 150$ , which is dense enough to ensure the accuracy of the results, and  $151 \times 151$ Monkhorst–Pack grids were used for the spin-dependent transport calculations.

### Results and discussion

In  $1T-MoS<sub>2</sub>/SCCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub>/2H-MoS<sub>2</sub>/SCCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub>/1T-MoS<sub>2</sub> vdW MTIs,$ the origin of TMR effects arise from the different densities of states for spin-up and spin-down channels of the  $SCCr_2C_2F_2$ layers, which act as the spin-filter tunnel barriers. The corresponding transportation mechanism is illustrated in Fig. 1. When the external magnetic fields are applied in vdW MTJs, the magnetic configurations of the two  $SCr_2C_2F_2$  layers are manipulated to parallel configuration (PC) and antiparallel configuration (APC) states, individually. The tunneling resistances in vdW MTJs vary widely varied in PC and APC. Herein, the TMR ratio is the most important factor in estimating the performance of the magnetic tunnel junctions, which is  $defined$  as<sup>60</sup>

$$
TMR = \frac{R_{\text{APC}} - R_{\text{PC}}}{R_{\text{PC}}} = \frac{2P_1P_2}{1 + P_1P_2} \tag{1}
$$

where  $R_{\text{APC}}$  and  $R_{\text{PC}}$  are the tunneling resistances in PC and APC, respectively.  $P_1$  and  $P_2$  represent the spin polarization of the left and right ferromagnetic materials, respectively. When the device is in the PC state, the spin-up electrons from the le  $1T-MoS<sub>2</sub>$  electrode can hop to the spin-up states around the Fermi level in the left  $SCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub>$  layer, which can further go through the  $2H-MoS<sub>2</sub>$  barrier layer due to the quantum tunneling effect. Subsequently, the spin-up electrons around the Fermi level can hop to the spin-up states of the right  $SCCr_2C_2F_2$  layer, and finally hop to the spin-up states of the right  $1T-MoS<sub>2</sub>$  electrode. However, owing to the semiconducting feature of the left  $SCr_2C_2F_2$  in the spin-down channel, a rare state is observed around the Fermi level. Hence, the spin-down electrons from the left  $1T-MoS<sub>2</sub>$  electrode cannot hop to the spin-down states of the left  $SCCr_2C_2F_2$  layer. As a result, the vdW MTJ is in a high conductivity state with the contribution of the conductive spin-up electron channel. When the device is in the APC state, both the spin-up and spin-down electrons can hardly pass through the vdW MTJ since the spin-up and spin-down electrons are prevented from hopping to the left and right  $SCCr_2C_2F_2$  layers, respectively. As a result, the vdW MTJ is in a high resistance state. Therefore, a considerable difference in Nanoscale Advances<br>
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Fig. 1 The electron tunneling mechanism of the  $1T-MoS<sub>2</sub>/SCCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub>/$ 2H-MoS<sub>2</sub>/ScCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub>/1T-MoS<sub>2</sub> MTJ in (a) PC and (b) APC states

the tunneling resistances is obtained from the  $1T-MoS_2/SCCr_2$ - $C_2F_2/2H-MoS_2/SCr_2C_2F_2/1T-MoS_2$  vdW MTJ with different spin configurations, where the high conductivity PC state and high resistance APC state are regarded as "1" and "0" states for data storage.<sup>61,62</sup>

The crystal structures of  $SCCr_2C_2F_2$ , 1T-MoS<sub>2</sub> and 2H-MoS<sub>2</sub> monolayers are shown in Fig. 2a-c. Herein,  $SCCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub>$  and 1T- $M_0S_2$  have hexagonal crystal structures with the space group of  $P\bar{3}m1$ , and 2H-MoS<sub>2</sub> has the space group of  $P\bar{6}m2$ . The optimized lattice constant of  $SCr_2C_2F_2$  is 3.12 Å. The optimized lattice constants of both 1T-MoS<sub>2</sub> and 2H-MoS<sub>2</sub> are 3.18  $\AA$ , which not only agrees well with the experimental values,<sup>63-66</sup> but also exhibits a perfect lattice match with  $SCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub>$ . Fig. 2d and f illustrates the calculated band structures for  $SCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub>$ , 1T- $MoS<sub>2</sub>$ , and 2H-MoS<sub>2</sub> monolayers. From Fig. 2d, ScCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub> shows the metallic properties in the spin-up channel and semiconducting properties in the spin-down channel, revealing its half-metallic magnetic features. On the other hand, from Fig. 2e and f, 1T-MoS<sub>2</sub> and 2H-MoS<sub>2</sub> are demonstrated to be metallic conducting and semiconducting, respectively. Therefore, 1T- $MoS<sub>2</sub>$  and  $2H-MoS<sub>2</sub>$  could be employed as the electrodes and tunnel barrier for the vdW MTJs.

In  $1T-MoS_2/SCCr_2C_2F_2/2H-MoS_2/SCCr_2C_2F_2/1T-MoS_2$  vdW MTJs, there are two important vdW interfaces: the  $SCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub>$ / 1T-MoS<sub>2</sub> interface and the ScCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub>/2H-MoS<sub>2</sub> interface. To find the stable interfacial connections in the vdW MTJs, we investigated the different stacking configurations of  $SCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub>/1T MoS<sub>2</sub>$  and  $ScCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub>/2H-MoS<sub>2</sub>$  heterostructures. As depicted in Fig. 3, each of them owns six different possible stacking configurations. For stacking-I of  $SCr_2C_2F_2/T-MoS_2$  heterostructure, the Mo atoms of the  $1T-MoS<sub>2</sub>$  layer lie on top of the upper F atoms of the  $SCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub>$  layer, and the upper Cr and C atoms sit right across the upper and bottom S atoms,



Fig. 2 The crystal structures and band structures for monolayers of (a) and (d)  $SCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub>$ , (b) and (e) 1T-MoS<sub>2</sub>, (c) and (f) 2H-MoS<sub>2</sub>.



Fig. 3 The structure schematic diagrams of (a)  $SCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub>/1T-MoS<sub>2</sub>$ heterostructure and (b) ScCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub>/2H-MoS<sub>2</sub> heterostructure with different stacking configurations.

respectively. Stacking-II and stacking-III are obtained from stacking-I by shifting the 1T-MoS<sub>2</sub> layer along the [110] direction of 1/3 and 2/3a, respectively. For stacking-IV, the Mo atoms of the  $1T-MoS<sub>2</sub>$  layer lie on top of the Sc atoms and upper F atoms of the  $SCr_2C_2F_2$  layer, and the upper Cr and C atoms sit right from the bottom and upper S atoms, respectively. Similarly, stacking-V and stacking-VI are obtained from stacking-IV by shifting the 1T-MoS<sub>2</sub> layer along the [110] direction of 1/3 and 2/ 3a, respectively. For stacking-I of  $SCCr_2C_2F_2/2H-MoS_2$  heterostructure, the Mo atoms of the  $2H-MoS<sub>2</sub>$  layer lie on top of the upper C atoms, and the S atoms sit right across the upper Cr atoms. For stacking-IV of  $SCr_2C_2F_2/2H-MoS_2$  heterostructures, the Mo atoms of the  $2H-MoS<sub>2</sub>$  layer lie on top of the upper Cr atoms, and the S atoms sit right across the upper C atoms. The transition of  $SCr_2C_2F_2/2H-MoS_2$  heterostructures from stacking-I to stacking-II/stacking-III and from stacking-IV to stacking-V/stacking-VI is the same as that in the  $SCr_2C_2F_2/1T$ -MoS<sub>2</sub> heterostructure.

To estimate the stabilities of the different stacking configurations, the binding energies  $(E_{bind})$  and formation energies  $(E<sub>form</sub>)$  were calculated using the following equations<sup>67,68</sup>

$$
E_{\text{bind}} = \left( E_{\text{ScCr}_2C_2F_2/MoS_2} - E_{\text{ScCr}_2C_2F_2}^{\text{fix}} - E_{\text{MoS}_2}^{\text{fix}} \right) / S \tag{2}
$$

$$
E_{\text{form}} = E_{\text{SCC}_2\text{C}_2\text{F}_2/\text{MoS}_2} - E_{\text{SCC}_2\text{C}_2\text{F}_2} - E_{\text{MoS}_2}
$$
(3)

Table 1 Formation energies  $E_{\text{form}}$  (meV) and binding energies  $E_{\text{bind}}$ (meV Å<sup>-2</sup>) of different stacking configurations of ScCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub>/1T-MoS<sub>2</sub> and  $SCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub>/1T-MoS<sub>2</sub>$  heterostructures

Stacking	$SCCr2C2F2/1T-MoS2$		$SCCr_2C_2F_2$ $2H-MoS2$		
	$E_{\rm form}$	$E_{\text{bind}}$	$E_{\rm form}$	$E_{\rm bind}$	
T	$-247.46$	$-29.88$	$-208.23$	$-25.15$	
Н	$-255.79$	$-30.91$	$-152.59$	$-18.69$	
Ш	$-193.68$	$-23.43$	$-152.39$	$-18.65$	
<b>IV</b>	$-250.63$	$-30.24$	$-201.82$	$-24.47$	
v	$-251.70$	$-30.48$	$-204.12$	$-24.64$	
VI	$-193.92$	$-23.44$	$-199.54$	$-24.15$	

where  $E_{\rm SCCr_2C_2F_2/MoS_2}$ is the total energy of the ScCr $_2\rm{C_2F_2/1T\text{-}MoS_2}$ (or  $SCr_2C_2F_2/2H-MoS_2$ ) heterostructures,  $E_{SCr_2C_2F_2}^{fix}$  and  $E_{MoS_2}^{fix}$ stand for the total energies of  $SCr_2C_2F_2$  and 1T-MoS<sub>2</sub> (or 2H- $MoS<sub>2</sub>$ ) monolayers constrained in the corresponding heterostructure lattice, respectively. S is the interface area.  $E_{\text{SCCr, C, F<sub>2</sub>}}$ and  $E_{\text{MoS}_2}$  represent the free-standing total energies of ScCr<sub>2</sub>- $C_2F_2$  and 1T-MoS<sub>2</sub> (or 2H-MoS<sub>2</sub>) monolayers. The calculated  $E_{\text{bind}}$  and  $E_{\text{form}}$  are summarized in Table 1. The negative  $E_{\text{bind}}$ and  $E_{\text{form}}$  demonstrate that all the stacking configurations of  $SCr_2C_2F_2/1T-MoS_2$  and  $SCr_2C_2F_2/2H-MoS_2$  heterostructures can form spontaneously. It is worth noting that the stacking-II of  $SCr_2C_2F_2/1T-MoS_2$  heterostructure and stacking-I of  $SCr_2$ - $C_2F_2/T-MoS_2$  heterostructure are more favorable to exist in experiments due to their lowest  $E_{bind}$  and  $E_{form}$  among various stacking configurations in Table 1. Based on the  $E_{\text{bind}}$  and  $E_{\text{form}}$ results, energetically-favorable stacking-II for the  $SCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub>/1T MoS<sub>2</sub>$  interface and stacking-I configurations for the  $ScCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub>$ /  $1T-MoS<sub>2</sub>$  interface were selected to construct the vdW MTJs.

The work function  $(W_G)$  and charge transfer between different materials in the MTJ could strongly influence the interfacial effects and the devices' performance.<sup>69,70</sup> To further understand the interfacial effects in the 1T-MoS<sub>2</sub>/ScCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub>/2H- $MoS_2/SCr_2C_2F_2/1T-MoS_2$  vdW MTJ, we calculated the electrostatic potential for the 1T-MoS<sub>2</sub>, 2H-MoS<sub>2</sub> and ScCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub> monolayers, as shown in Fig. 4a–c, respectively. The work function is defined as the difference between the vacuum energy level and the Fermi level of a 2D material. As depicted in Fig. 4a-c, the values of  $W_G$  for 1T-MoS<sub>2</sub>, 2H-MoS<sub>2</sub>, and ScCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub> monolayers are 5.06, 5.84, and 6.78 eV, respectively. When two different 2D materials are in contact, the electrons of the lower work function side will flow to the higher work function side until their Fermi levels are equal.<sup>71</sup> Therefore, the interlayer charge transfers from  $1T-MoS_2/2H-MoS_2$  to  $ScCr_2C_2F_2$  layers are inferred due to the difference in work functions. To verify the corollary, the charge redistributions in the corresponding 1T- $MoS<sub>2</sub>/SCCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub>/2H-MoS<sub>2</sub>/SCCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub>/1T-MoS<sub>2</sub> heterostructure$ are represented from the differential charge density plots in Fig. 4d and e. As seen in the interfacial regions marked with magenta dashed boxes, charge accumulations occur at the F terminations in the  $SCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub>$  layers, and charge depletions are found at the S terminations in the  $1T-MoS_2$  and  $2H-MoS_2$  layers.



Fig. 4 The electrostatic potential  $E<sub>p</sub>$  for (a) 1T-MoS<sub>2</sub>, (b) monolayer ScCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub> and (c) 2H-MoS<sub>2</sub>. The differential charge density of 1T-MoS<sub>2</sub>/  $\mathsf{SCC}_\mathrm{Z}$ C<sub>2</sub>F<sub>2</sub>/2H-MoS<sub>2</sub>/ScCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub>/1T-MoS<sub>2</sub> heterostructure in (d) PC and (e) APC states. The isosurface value is set to 0.0002 e bohr<sup>−1</sup>,<sup>3</sup> and the yellow and cyan regions represent the accumulation and depletion of electrons, respectively. The magenta dashed box represents the interfacial region.

To investigate whether the half-metallicity of  $SCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub>$  can be retained in vdW MTJs, we calculated the spin-dependent projected band structures of the 1T-MoS<sub>2</sub>/ScCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub>/2H-MoS<sub>2</sub>/  $SCC<sub>2</sub>C<sub>2</sub>F<sub>2</sub>/1T-MoS<sub>2</sub>$  heterostructure when the  $SCC<sub>2</sub>C<sub>2</sub>F<sub>2</sub>$  layers are in PC and APC states. Compared with the band structures of corresponding monolayers in Fig. 2, the projected band structures of the  $1T-MoS<sub>2</sub>$  and  $2H-MoS<sub>2</sub>$  layers move up with respect to the Fermi level, as shown in Fig. 5a, c and e. On the other hand, a conversely downward shift is found for the projected band structures of the  $SCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub>$  layers, as shown in Fig. 5b and d. The energy-level shift agrees well with the charge transfers of electrons in the process of forming the heterostructure we have shown previously. Furthermore, the half-metallic electronic structures of the left and right  $SCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub>$  layers are well maintained, and only the spin-up channel of the PC state is conductive, while the other three channels are insulating. The difference in transmission mainly comes from the spin-up channel of  $SCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub>$  that allows the electrons to pass through, while its spin-down channel prevents electrons from passing through. Therefore, the spin filter effect is mainly contributed by the spin-resolved band structures of  $SCCr_2C_2F_2$ , rather than the interface between  $SCr_2C_2F_2$  and  $2H-MoS_2$ . Tis phenomenon reveals a large conductivity difference between PC and APC states, which indicates a distinguished performance of the  $SCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub>$ -based vdW MTJs.

Furthermore, to understand the thickness effects of the tunnel barrier, odd layer number  $2H-MoS<sub>2</sub>$  with different layer n  $(n = 1, 3, 5)$  was taken into account, following the principle of control variables. In the following discussion,  $1T-MoS_2/SCCr_2$ - $C_2F_2/2H-MoS_2/SCr_2C_2F_2/1T-MoS_2$  vdW MTJs with one, three and five  $2H-MoS<sub>2</sub>$  layers are abbreviated as MTJ-HM, MTJ-3HM and MTJ-5HM, respectively. The corresponding atomically structured schematics of the vdW MTJs are illustrated in Fig. 6. Herein, after the full-structure optimizations of the vdW MTJs, the relaxed interface distances between different materials are summarized in Table 2. For all the vdW MTJs, the distances between 2H-MoS<sub>2</sub> and ScCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub> ( $d_{\text{LC}}$  and  $d_{\text{RC}}$ ) are around 2.7-3 Å, and the distances between 1T-MoS<sub>2</sub> and ScCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub> ( $d<sub>L</sub>$  and  $d_{\rm R}$ ) hold smaller values around 2.4–2.5 Å, revealing weak vdW connections in the MTJs.

To investigate the spin-dependent transport properties, we calculated the transmission coefficients at the equilibrium state for the 1T-MoS<sub>2</sub>/ScCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub>/2H-MoS<sub>2</sub>/ScCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub>/1T-MoS<sub>2</sub> vdW MTJs. Fig. 7 shows the zero-bias transmission coefficient curves from −1.2 eV to 1.2 eV for MTJ-HM, MTJ-3HM, and MTJ-5HM in PC and APC states. For all the vdW MTJs in the PC state, the maximum spin-up and spin-down transmission coefficients appear around −1 eV below the Fermi level, and the spin-down transmission coefficients suffer more reduction than spin-up transmission coefficients with the energy region approaching the Fermi level. Therefore, the spin-up transmission coefficients at the Fermi level are several orders of magnitude larger than the spin-down transmission coefficients. Herein, the spin-up channel plays a decisive role in the transmission process. When the vdW MTJs are in an APC state, the spin-up transmission coefficients are almost equivalent to the spin-down transmission coefficients of the entire energy region, and the minimum values occur around the Fermi level. Hence, the transmission capacity of both spin channels is tiny in the APC state.

To quantitatively analyse the device performance of the  $1T-MoS_2/ScCr_2C_2F_2/2H-MoS_2/ScCr_2C_2F_2/1T-MoS_2$  vdW MTJs,



Fig. 5 The spin-dependent projected band structures of (a) left-1T-MoS<sub>2</sub> (b) left-ScCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub> (c) 2H-MoS<sub>2</sub> (d) right-ScCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub> and (e) right-1T-MoS<sub>2</sub> in the 1T-MoS<sub>2</sub>/ScCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub>/2H-MoS<sub>2</sub>/ScCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub>/1T-MoS<sub>2</sub> heterostructure.

the TMR ratios can be calculated using the following equation $14,72$ 

$$
\text{TMR} = (G_{\text{PC}} - G_{\text{APC}}) / G_{\text{APC}} \times 100\% \tag{4}
$$

where  $G_{\text{PC}}$  and  $G_{\text{APC}}$  are the total spin-dependent conductance of the PC and APC states, which are defined as

$$
G_{\rm PC} = T_{\rm PC}^{\uparrow}(E_{\rm f}) + T_{\rm PC}^{\downarrow}(E_{\rm f}) \tag{5}
$$

$$
G_{\rm APC} = T_{\rm APC}^{\dagger}(E_{\rm f}) + T_{\rm APC}^{\dagger}(E_{\rm f}) \tag{6}
$$

where  $T_{\rm PC}^{\uparrow}(E_{\rm f})$  and  $T_{\rm PC}^{\downarrow}(E_{\rm f})$  represent the spin-up and spin-down transmission coefficients at the Fermi level when the vdW MTJs are in the PC state, and  $T_{\text{APC}}^{\uparrow}(\mathit{E}_{\text{f}})$  and  $T_{\text{APC}}^{\downarrow}(\mathit{E}_{\text{f}})$  represent the spinup and spin-down transmission coefficients, respectively, at the Fermi level when the vdW MTJs are in the APC state. Table 3 lists the calculated spin-dependent transmission coefficients at the Fermi level, total spin-dependent conductances, and TMR



Fig. 6 The schematic illustrations of 1T-MoS<sub>2</sub>/ScCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub>/2H-MoS<sub>2</sub>/ScCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub>/1T-MoS<sub>2</sub> vdW MTJs with (a) one (MTJ-HM) (b) three (MTJ-3HM) and (c) five (MTJ-5HM) 2H-MoS<sub>2</sub> tunnel barrier layers.

Table 2 The interface distances  $d_{\mathsf{L}}$ ,  $d_{\mathsf{LC}}$ ,  $d_{\mathsf{RC}}$  and  $d_{\mathsf{R}}$  (Å) of left-1T- $\mathsf{MoS}_2/\mathsf{left}\text{-}\mathsf{SCCr}_2\mathsf{C}_2\mathsf{F}_2,\quad \textsf{left}\text{-}\mathsf{SCCr}_2\mathsf{C}_2\mathsf{F}_2/\mathsf{2H}\text{-}\mathsf{MoS}_2,\quad \textsf{2H}\text{-}\mathsf{MoS}_2/\mathsf{right}\text{-}$ ScCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub> and right-ScCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub>/right-1T-MoS<sub>2</sub> interfaces in different vdW MTJs

<b>MTJs</b>	$d_{\rm L}$	$d_{\rm LC}$	$d_{\rm RC}$	$d_{\rm R}$
MTI-HM	2.44	3.01	2.93	2.49
MTJ-3HM	2.48	2.76	2.76	2.48
MTI-5HM	2.48	2.72	2.78	2.44

ratios. It was observed that the total spin-dependent conductances decrease exponentially with the increase in the  $2H-MoS<sub>2</sub>$ barrier layers. It was noted that  $G_{\text{PC}}$  of MTJ-HM is five orders of magnitude larger than  $G_{APC}$ , which results in the giant TMR ratios of 2.95  $\times$  10 $^{6}$ %. Interestingly, although,  $G_{\rm PC}$  and  $G_{\rm APC}$  was reduced by several orders of magnitude, when the tunnelbarrier  $2H-MoS<sub>2</sub>$  increases to three layers, the TMR ratio of MTJ-3HM increases to 6.95  $\times$  10 $^{6}$ % since the corresponding  $G_{\rm PC}$ is six orders of magnitude larger than  $G_{APC}$ . Besides, when the number of tunnel-barrier  $2H$ -MoS<sub>2</sub> increases to five layers, the TMR ratios of MTJ-5HM decrease to 9.24  $\times$  10<sup>5</sup>%, which is still



Fig. 7 The transmission coefficients for (a) MTJ-HM, (b) MTJ-3HM, and (c) MTJ-5HM in PC and APC states.

a considerable giant value. Furthermore, the transmission calculations by including the spin–orbit coupling (SOC) are shown in Table S1.† It is noted that the SOC should contribute to the spin-flip scattering, enhancing the transmission probability in antiparallel configuration and reducing the TMR. Nevertheless, the proposed vdW MTJ devices showed considerable TMR values at a 10<sup>4</sup>% level.

Moreover, we calculated the spin-dependent  $k_{\parallel}$ -resolved transmission spectrums at the Fermi level to better represent the physical origin of the giant TMR effects in the  $1T-MoS<sub>2</sub>/$  $SCCr_2C_2F_2/2H-MoS_2/SCCr_2C_2F_2/1T-MoS_2$  vdW MTJs. Herein, Fig. 8 illustrates the transmission spectrum of MTJ-3HM as an example since it shows the highest TMR ratio. For reference, the transmission spectra of MTJ-HM and MTJ-5HM are presented in Fig. S3 and S4,† respectively. Fig. 8a shows that there are six crescent-shaped high transmission regions in the spin-up transmission spectrum for MTJ-3HM in the PC state. However, there is no distinguishable high transmission region in the whole  $k_{\parallel}$ -resolved regions for the spin-down transmission spectrum in Fig. 8b. On the other hand, the transmission regions of both spin-up and spin-down channels are similar for MTJ-3HM in the APC state. Herein, it is noted that the transmission capacity of the APC state is several orders of magnitude smaller than that of the PC state, which leads to the apparent TMR effect. In addition, the spin-dependent projected local density of states of MTJ-HM, MTJ-3HM, and MTJ-5HM along the Nanoscale Advances<br>
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Fig. 8 The spin-dependent  $k_{\parallel}$ -resolved transmission spectrums of MTJ-3HM at the Fermi level for (a) spin-up and (b) spin-down channels in the PC state and (c) spin-up and (d) spin-down channels in the APC state.

Table 3 The calculated transmission coefficients (e<sup>2</sup>/h) of the spin-up channel in the PC state  $\mathcal{T}_\text{PC}^{\uparrow}(E_\text{f})$ , spin-down channel in the PC state  $\mathcal{T}^\downarrow_{\text{PC}}(E_\text{f})$ , spin-up channel in the APC state  $\mathcal{T}^\uparrow_{\text{APC}}(E_\text{f})$ , and spin-down channel in the APC state  $\mathcal{T}^\downarrow_{\text{APC}}(E_\text{f})$ , total spin-dependent conductances (e<sup>2</sup>/h) in the PC state  $G_{PC}$  and the APC state  $G_{APC}$ , and TMR ratios for MTJ-HM, MTJ-3HM, and MTJ-5HM devices

MTJs	$T_{\rm PC}{}^{\top}(E_{\rm f})$	$T_{\rm PC}^{\;\downarrow}(E_{\rm f})$	$T_{\text{APC}}{}^{\uparrow}(E_{\text{f}})$	$T_{\text{APC}}^{+}(E_{\text{f}})$	$G_{\rm PC}$	$G_{\rm APC}$	TMR $(\% )$
MTJ-HM MTJ-3HM MTJ-5HM	$1.19 \times 10^{-5}$ $1.30 \times 10^{-8}$ $5.51 \times 10^{-11}$	$1.76 \times 10^{-12}$ $3.43 \times 10^{-15}$ $1.96\times10^{-15}$	$2.03 \times 10^{-10}$ $9.36 \times 10^{-14}$ $2.32 \times 10^{-15}$	$2.02 \times 10^{-10}$ $9.27 \times 10^{-14}$ $3.64\times10^{-15}$	$1.19 \times 10^{-5}$ $1.30 \times 10^{-8}$ $5.51 \times 10^{-11}$	$4.05 \times 10^{-10}$ $1.86\times10^{-13}$ $5.96 \times 10^{-15}$	$2.95 \times 10^{6}$ $6.95 \times 10^{6}$ $9.24 \times 10^{5}$



Fig. 9 The spin-dependent projected local density of states of MTJ-3HM for (a) spin-up and (b) spin-down channels in the PC state, (c) spin-up, and (d) spin-down channels in the APC state.

transport direction are shown in Fig. S5, 9 and S6,† respectively. The corresponding vdW MTJ model is illustrated in the bottom panel for reference. Regardless of the PC or APC states, it was observed that the 1T-MoS<sub>2</sub> electrodes and  $2H-MoS<sub>2</sub>$  barriers still exhibit their metallic and semiconducting properties, respectively. However, the  $SCr_2C_2F_2$  monolayer shows metallic properties in the spin-up channel but presents a semiconducting feature in the spin-down channel in the PC state and vice versa in the APC state. As a result, in the PC state, for the electron transport process from the left to right in the 1T- $MoS<sub>2</sub>$  electrodes, the spin-up electrons only need to go through the potential barrier of the  $2H-MoS<sub>2</sub>$  layer. However, the spindown electrons have to overcome a much higher potential barrier, which is from the left and right  $SCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub>$  layers as well as the  $2H-MoS<sub>2</sub>$  layers. On the other hand, in the APC state, the spin-up (spin-down) electrons have to overcome the potential barriers of the right (left)  $SCCr_2C_2F_2$  layer and the 2H-MoS<sub>2</sub> layers for the electron transport process from the left to right 1T- $MoS<sub>2</sub>$  electrodes. Therefore, the spin-up electrons in the PC state are proved to play a decisive role in the transmission behavior, which agrees well with our previously electronic structure analysis.

# Conclusion

In summary, by combining density functional theory and nonequilibrium Green's function calculations, we investigated the transport properties of  $1T-MoS_2/SCCr_2C_2F_2/2H-MoS_2/SCCr_2$ - $C_2F_2/1T-MoS_2$  vdW MTJs with different thicknesses of the 2H- $MoS<sub>2</sub>$  tunnel barrier. The different stacking configurations of  $SCCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub>$  relative to 1T-MoS<sub>2</sub> and 2H-MoS<sub>2</sub> were firstly studied to determine the stable interface configurations. The calculated formation energies and binding energies indicated that all the

interface configurations can form spontaneously. Besides, the interlayer charge transfers from the  $1T-MoS_2/2H-MoS_2$  to  $SCr<sub>2</sub>C<sub>2</sub>F<sub>2</sub>$  layers can be inferred due to the work function differences. The projected band structures of the corresponding  $1T-MoS_2/SCCr_2C_2F_2/2H-MoS_2/SCCr_2C_2F_2/1T-MoS_2$  heterostructure revealed that the  $SCr_2C_2F_2$  monolayer can still maintain half-metallicity with perfect polarization in vdW MTJs. Subsequently, the thickness of the  $2H-MoS<sub>2</sub>$  tunnel barrier was considered for further performance optimizations. It is remarkable to note that all the vdW MTJs hold giant TMR ratios over 9  $\times$  10<sup>5</sup>%, and the maximum TMR ratio of 6.95  $\times$  10<sup>6</sup>% was obtained in vdW MTJ with a trilayer  $2H-MoS<sub>2</sub>$  tunnel barrier, demonstrating the potential of such vdW MTJs for applications.

# Conflicts of interest

The authors declare no competing financial interest.

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